

**Please provide the following information.**

This will allow us to select the appropriate pieces of equipment for your application.

Customer Name	
Affiliation	
Address	
Email	

1. What is your main field of research with the new MBE system? (III-V MBE, topological insulator research, laser diode fabrication, oxide material growth, SiGe MBE ....) \_\_\_\_\_
2. What substrate materials do you want to use? (Si, GaAs, Sapphire, SrTiO<sub>3</sub> ...) \_\_\_\_\_  
\_\_\_\_\_
3. What will be the maximum substrate size? (10x10 mm<sup>2</sup> or 2, 3, 4, 6 or 8 inch wafers) \_\_\_\_\_  
\_\_\_\_\_
4. Which materials do you want to evaporate? (Please provide a list.) \_\_\_\_\_  
\_\_\_\_\_
5. Which compounds do you want to grow? (GaAs, InP, SrBaCuO, ...) \_\_\_\_\_  
\_\_\_\_\_
6. What kind of in-situ analysis do you need? (RHEED, Pyrometer, RGA, others..) \_\_\_\_\_  
\_\_\_\_\_
7. Do you need a preparation chamber? (For example for substrate heating in atomic H...) \_\_\_\_\_  
\_\_\_\_\_
8. Do you have a preference for the MBE chamber pumping system? (Cryopump, Turbopump, Ion Getter Pump, ...) \_\_\_\_\_  
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